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23373 7590 02/06/2006 SUGHRUE MION, PLLC MACARTHUR, SYLVIA 2100 PENNSYLVANIA AVENUE, N.W.	PPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
SUGHRUE MION, PLLC MACARTHUR, SYLVIA 2100 PENNSYLVANIA AVENUE, N.W.	10/676,032	10/02/2003	Masaharu Takizawa	Q77826	6923
2100 PENNSYLVANIA AVENUE, N.W.	23373	7590 02/06/2006		EXAM	INER
APTIBUT	2100 PENNSYLVANIA AVENUE, N.W.			MACARTHUR, SYLVIA	
				ART UNIT	PAPER NUMBER
WASHINGTON, DC 20037				1763	

DATE MAILED: 02/06/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	Application ito.	Applicant(s)				
Office Action Commence	10/676,032	TAKIZAWA, MASAHARU				
Office Action Summary	Examiner	Art Unit				
	Sylvia R. MacArthur	1763				
The MAILING DATE of this communication Period for Reply	appears on the cover sheet with	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR RIWHICHEVER IS LONGER, FROM THE MAILING. - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period for reply within the set or extended period for reply will, by some Any reply received by the Office later than three months after the rearned patent term adjustment. See 37 CFR 1.704(b).	G DATE OF THIS COMMUNIC FR 1.136(a). In no event, however, may a re n. eriod will apply and will expire SIX (6) MON statute, cause the application to become AB	CATION. Eply be timely filed THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on (02 October 2003					
	This action is non-final.					
3) Since this application is in condition for all		ers, prosecution as to the merits is				
closed in accordance with the practice und	·	•				
Disposition of Claims						
	ation					
 4) Claim(s) 1-19 is/are pending in the application. 4a) Of the above claim(s) 12-19 is/are withdrawn from consideration. 						
5) Claim(s) is/are allowed.	diawii iioiii consideration.					
6)⊠ Claim(s) is/are allowed.						
7) Claim(s) 1-11 is/are rejected. 7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction a	nd/or election requirement					
	·					
Application Papers						
9) The specification is objected to by the Exar	miner.					
10)⊠ The drawing(s) filed on <u>02 October 2003</u> is	/are: a)⊠ accepted or b)□ ob	ejected to by the Examiner.				
Applicant may not request that any objection to	the drawing(s) be held in abeyand	ce. See 37 CFR 1.85(a).				
Replacement drawing sheet(s) including the co	rrection is required if the drawing(s	s) is objected to. See 37 CFR 1.121(d).				
11) The oath or declaration is objected to by the	e Examiner. Note the attached	Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for fore a)⊠ All b)□ Some * c)□ None of:	eign priority under 35 U.S.C. §	119(a)-(d) or (f).				
1. Certified copies of the priority docum	pents have been received					
2. Certified copies of the priority docum		oplication No.				
3. Copies of the certified copies of the	•	·				
application from the International Bu	•					
* See the attached detailed Office action for a	•	received.				
	·					
Attachment(s)						
1) Notice of References Cited (PTO-892)	, 	ummary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948 3) Notice of Draftsperson's Patent Drawing Review (PTO-948	· I)/Mail Date formal Patent Application (PTO-152)				
Paper No(s)/Mail Date <u>7/8/2004</u> .	6) Other:	· · · · · · · · · · · · · · · · · · ·				

Office Action Summary

DETAILED ACTION

Election/Restrictions

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
 - I. Claims 1-11, drawn to an apparatus for removing edge pool, classified in class156, subclass 345.55.
- II. Claims 12-19, drawn to a coating method, classified in class 427, subclass 352. The inventions are distinct, each from the other because of the following reasons:
- 2. Inventions II and I are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the apparatus can be used to apply a coating material at the edge on a wafer side surface.
- 3. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.
- 4. During a telephone conversation with Howard Bernstein on January 17, 2006 a provisional election was made with traverse to prosecute the invention of Group I, claims 1-11. Affirmation of this election must be made by applicant in replying to this Office action. Claims 12-19 are withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention.

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Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

2. Claims 1-11 are rejected under 35 U.S.C. 102(e) as being anticipated by Saito et al (US 2003/041968).

Saito et al teaches a substrate processing apparatus wherein

Regarding claim 1: A coating apparatus for removing edge pool formed on a wafer side surface of a coating film deposited on a wafer by edge rinse treatment using a rinse solution, comprising:

a mechanism 14 in which the edge rinse treatment is performed using a rinse solution containing a mixture of solvents having different dissolving rates for dissolving the coating film, see abstract and sections[004,005].

Regarding claim 2: The coating apparatus according to Claim 1, wherein the dissolving rates vary in accordance with types of coating film, and the mixture of solvents minimizes an edge hump of the coating film, see the abstract. Regarding claim 3: The coating apparatus according to Claim 1, wherein the mechanism comprises a flow adjust device (solenoid operated valves, see [0056] for changing a ratio between the solvents contained in the rinse solution in accordance with thecoating film.

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Regarding claim 4: The coating apparatus according to Claim 3, wherein the ratio between the solvents contained in the rinse solution is adjusted using the flow adjust device in accordance with the dissolving rate for dissolving the coating film, see sections [0056,0057].

Regarding claim 5: The coating apparatus according to Claim 1, wherein the coating film is an organic antireflection film or a photoresist film. This claim is a matter of an intended use, does not provide structural limitation and is not given patentable weight, also note that the apparatus of Saito et al is capable of removing the edge pool of the films listed in claim 5.

Regarding claim 6: The coating apparatus according to Claim 5, wherein the solvents comprise isopropyl alcohol and polyethylene glycol monomethyl ether acetate. This claim is a matter of an intended use, does not provide structural limitation and is not given patentable weight, also note that the apparatus of Saito et al is capable of removing the edge pool using the solvents discussed in claim 6.

7. A coating apparatus for removing edge pool formed on a wafer side surface of a coating film deposited on a wafer by edge rinse treatment using a rinse solution, comprising:

a mechanism in which the edge rinse treatment is performed using any one selected from solvents having different dissolving rates for dissolving the coating film, the any one selected from solvents being used as the rinse solution see abstract and sections[004,005].

8. The coating apparatus according to Claim 7,

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wherein the dissolving rates vary in accordance with types of coating film, and the any one selected from the solvents minimizes an edge hump of the coating film see the abstract.

- 9. The coating apparatus according to Claim 7,
- wherein the mechanism comprises rinse nozzles (supply pipes where nozzles are inherently present are discussed in [0052 and 0058] for supplying the solvents having different dissolving rates for dissolving the coating film.
- 10. The coating apparatus according to Claim 7,

wherein the coating film is an organic antireflection film or a photoresist film This claim is a matter of an intended use, does not provide structural limitation and is not given patentable weight, also note that the apparatus of Saito et al is capable of removing the edge pool of the films listed in claim 10.

1 1. The coating apparatus according to Claim 10,

wherein the solvents comprise isopropyl alcohol and polyethylene glycol monomethyl ether acetate This claim is a matter of an intended use, does not provide structural limitation and is not given patentable weight, also note that the apparatus of Saito et al is capable of removing the edge pool using the solvents discussed in claim 11.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sylvia R. MacArthur whose telephone number is 571-272-1438. The examiner can normally be reached on M-F during the core hours of 9 a.m. and 3 p.m.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

ylvia R MacArthur atent Examiner

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January 22, 2006